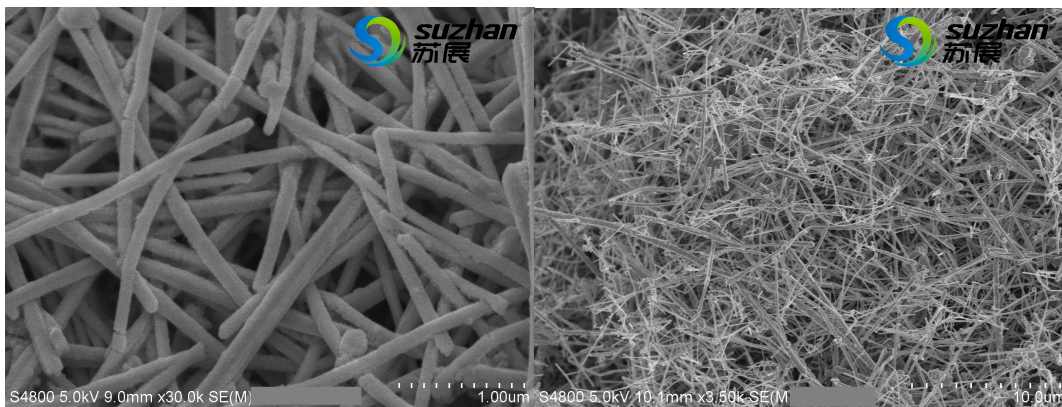


SZ-005-1 铜纳米线

1 技术参数 (Specification)

产品 Product	铜纳米线 Copper Nanowires
牌号 ID	SZ-005-1
直径 Diameter	50-200nm
长度 Length	10-30 μ m
浓度 Concentration	10 mg/ml
溶剂 Solvent	乙醇、水 Ethanol or water

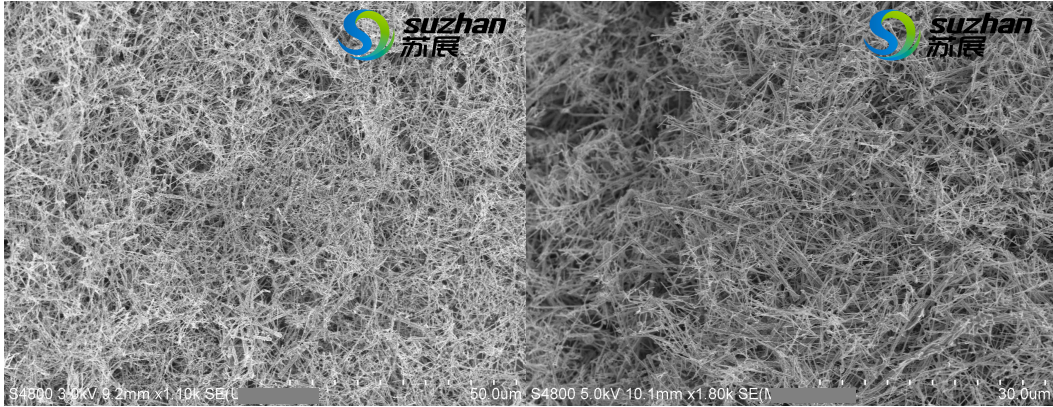
2 表征测试 (Characterizations)



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3 应用领域 (Application Fields)

透明导电薄膜、柔性显示器、太阳能电池板、传感器、催化剂等。

Transparent conductive films, flexible displays, solar panels, sensors, catalysts, etc.

4 储存条件(Storage Conditions)

4℃冷藏密封保存，在未引入污染源的情况下最长保存期限为 1 个月。

Sealed and keep at 4℃. Expiry date: The maximum shelf life is one month without the introduction of a source of pollution.

5 使用须知 (Terms and Conditions)

铜纳米线有沉底现象是正常的，请使用前在稍大功率的超声波清洗器中振荡超声，可辅以搅拌棒搅拌。一般 300 W 以内超声功率是可以的，时间不超过 3 min。若为 600-800 W，则不超过 1 min。分散均匀后可维持一段时间不沉降。

It is normal that the Cu nanowires will precipitate in the bottle. Please sonicate it using a ultrasonic cleaner with a slightly higher power , and stir with a stirring rod. Generally, less than 3 min with 300W ultrasonic power and less than 1 min with 600-800 W ultrasonic power. After uniform dispersion, it can be maintained for a period of time without sedimentation.

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10/18/2018 Ed